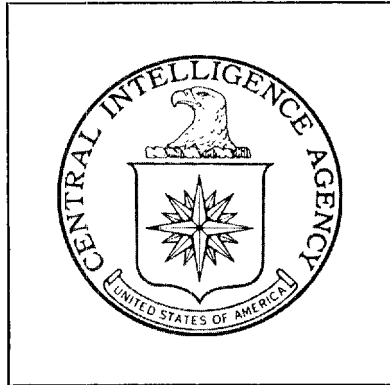


Top Secret



DIRECTORATE OF
INTELLIGENCE

Industrial Facilities
(Non-Military)

Basic Imagery Interpretation Brief

Shang-hai Chemical Plant Wu-ching

Shang-hai, China

25X1A

*Handle via Talent - Keyhole
Channels Only*

DECLASS REVIEW by NIMA/DOD

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BCS 13/0096/69
TCS 12171/68
DATE FEBRUARY 1969
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PAGES 2

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Feb. 1969

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Handle Via
Talent-KEYHOLE
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TOP SECRET RUFF

TOP SECRET RUFF
BCS - 13/0096/69

CENTRAL INTELLIGENCE AGENCY
Directorate of Intelligence
Imagery Analysis Service

INSTALLATION OR ACTIVITY NAME			COUNTRY	
Shang-hai Chemical Plant Wu-ching			CH	
UTM COORDINATES	GEOGRAPHIC COORDINATES		COMIREX NO.	WAC-PI C NO.
51RUE532399	31-04-30N 121-27-50E		None	0492-48C3
MAP REFERENCE				
2nd RTS. USATC Series 200, Sheet M0492-7HL, 3rd edition, May 68, Scale 1:200,000 (SECRET NO FOREIGN DISSEM [REDACTED] CONTROLLED DISSEM)				
LATEST IMAGERY USED		NEGATION DATE (If required)		
[REDACTED]		Not Required		

NOTICE

The following is designated as the Basic Report for this installation:

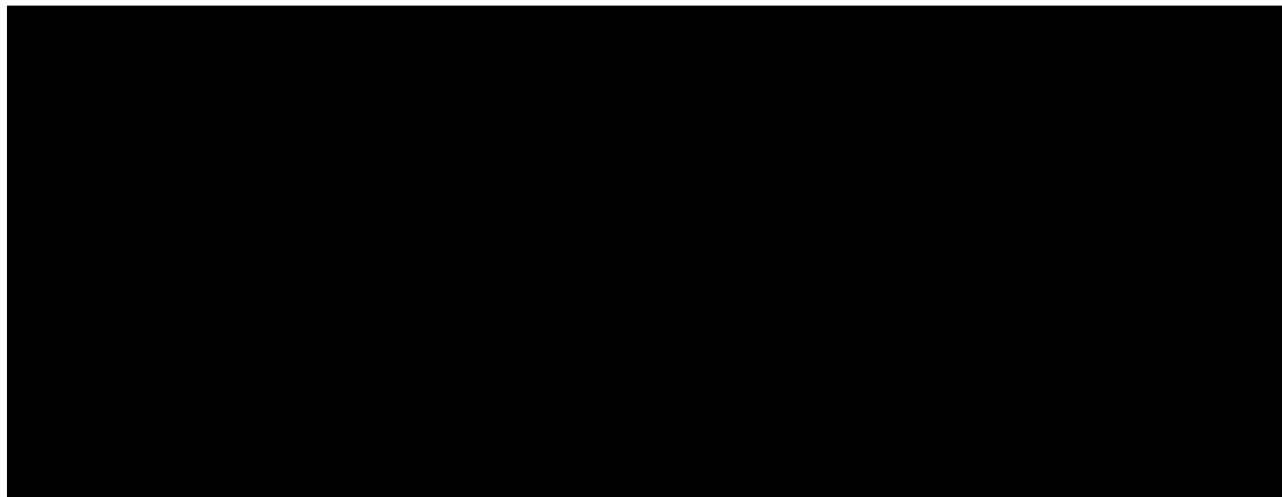
CIA. PIR 65105, Wu-ching Chemical Fertilizer Plant, Shang-hai, China,
April 1966 (SECRET NO FOREIGN DISSEM [REDACTED])

The title and coordinates in the Data Block are correct; those in the
the referenced report are in error.

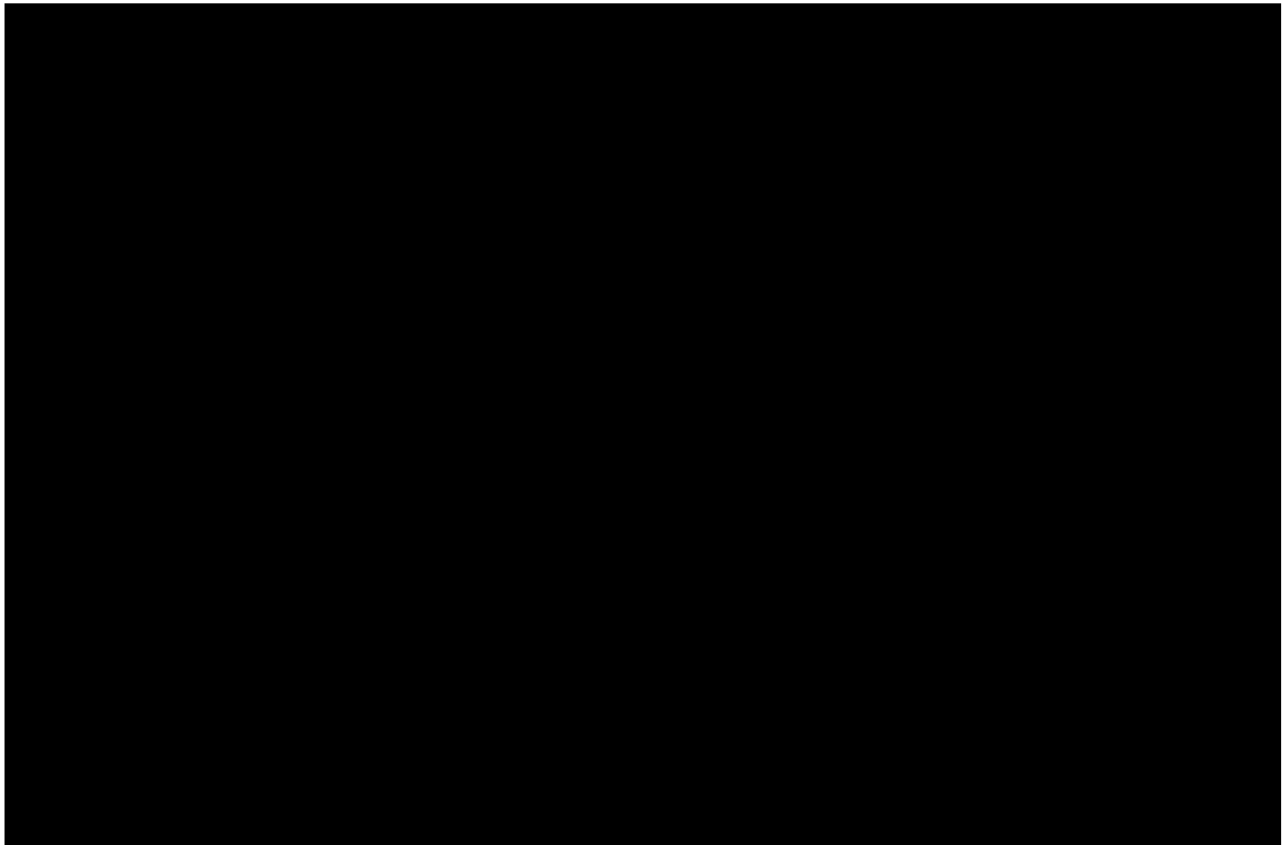
BASIC DESCRIPTION

This plant appeared to be operating on all photographic coverage since
the previous report. No expansion or new construction was observed.

REFERENCES



25X1D



Requirement

EXSUBCOM - BR-N/002-69

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